

**Electronic Supplementary Information (ESI) to "Nanopore-mediated ultrashort
laser-induced formation and erasure of volume nanogratings in glass"**

Anton Rudenko,^{*} Jean-Philippe Colombier,[†] and Tatiana E. Itina[‡]
*Univ Lyon, UJM-St-Etienne, Laboratoire Hubert Curien,
CNRS UMR 5516, F-42000, Saint-Etienne, France*
(Dated: January 15, 2018)

^{*} anton.rudenko@univ-st-etienne.fr

[†] jean.philippe.colombier@univ-st-etienne.fr

[‡] tatiana.itina@univ-st-etienne.fr

Table I. Optical and thermo-mechanical properties of fused silica.

Physical properties	Fused silica
Density $\rho[g/cm^3]$	2.2 ^{a,c,n,p,q,t}
Refractive index ($\lambda = 800$ nm)	1.45 ^{d,g}
Electron band gap $E_g[eV]$	9 ^d , 9.3 ^m , 7.2-7.8 ^{c,f,j}
Kerr effect $10^{-16}[cm^2/W]$	3.54 ^{d,g} , 3.89 ⁱ
Electron collision time $[fs]$	0.2-23.3: 0.5 ^v , 1.27 ^d , 10 ^g
Electron recombination time $\tau_{rec}[ps]$	0.06 ^s , 0.15 ^{i,g,r,d,m} , 1-2 ^{u,v} , 30 ^c , > 100 ^{u,v}
Photoionization rate w_{pi}	Keldysh ^g
$\lambda = 800$ nm $\sigma_6[\frac{m^9}{W^6s}]$	6-photon: $2 \cdot 10^{-65d,m,g}$, $6 \cdot 10^{-63e,l,g}$, $3.15 \cdot 10^{-67s,g}$
Heat capacity $C_i[J/(kgK)]$	772-790 ^{a,t} , 730-752 ^{b,d,n} , 1335-1440 ^x (1600-2400K), 1450 ^{c,w} (1873K), 704-845 ^f , 1100 ^q
Thermal conductivity $k_i[W/(mK)]$	1.31 ^t , 1.38-1.4 ^{a,n} , 1.4-2.514 ^b , 1.38-1.67 ^f , 1.4-3.0 ^{h,w} (300-2500K)
Softening temperature $T_{melt}[K]$	2000-2006 ^{b,q,e} , 1873-1875 ^{c,t} , 1750 ⁿ , 1993 ^p
Thermal diffusivity, $10^{-7}D[m^2/s]$	5.9
Shear modulus $G[GPa]$	31.2 ^{b,w} , 30-33.5 ^k (200-1800K), 31-33 ^p (300-1700K)

^{a-f}References 1, 2, 3, 4, 5, 6. ^{g-1}References 7, 8, 9, 10, 11, 12. ^{m-t}References 13, 14, 15, 16, 17, 18, 19,20.
^{u-x}References 21, 22, 23, 24.

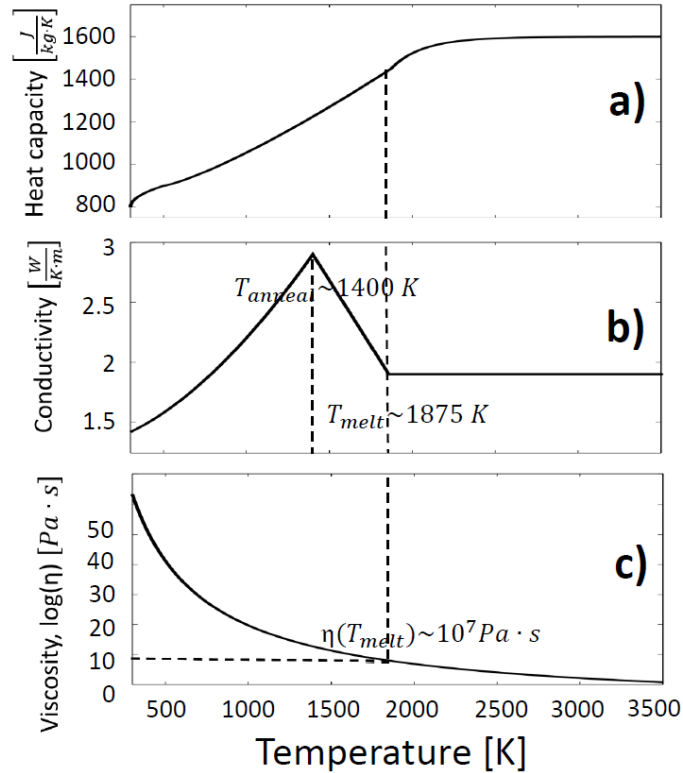


Figure 1. Heat capacity, thermal conductivity and viscosity temperature dependencies for fused silica glass.

APPENDIX: THERMO-ELASTIC PROPERTIES OF FUSED SILICA

The temperature dependence of ion heat capacity for fused silica is plotted in Fig. 1(a). The values are taken from recent experimental data [3, 25] approximated as

$$C_i = \begin{cases} 1.6 \cdot \left(1 + \sqrt{\frac{T_i - 300}{200}}/8\right) \frac{MJ}{m^3K}, & 300K \leq T_i < 500K \\ 1.8 \cdot \left[1 + \left(\frac{T_i - 500}{1375}\right)^{1.25} \frac{11}{18}\right] \frac{MJ}{m^3K}, & 500K \leq T_i < 1875K \\ \left[3.2 - 0.3 \left(\frac{1875}{T_i}\right)^{10}\right] \frac{MJ}{m^3K}, & T_i \geq 1875K, \end{cases} \quad (1)$$

consistent with the experimentally reported values given in Table I. In fact, the heat capacity C_i significantly increases with temperature (see Suppl. Info in Ref. [24]). For instance, if the value corresponding to the initial conditions is taken ($C_i \approx 800$ J/(kgK)) instead of the temperature dependent heat capacity given by (1), the lattice temperatures for the considered laser irradiation conditions are overestimated by more than 50%.

An adaptive fit is used to reproduce the temperature dependence of the fused silica thermal conductivity with slope discontinuities at the annealing temperature $T_{anneal} = 1400$ K and the melting temperature $T_{melt} = 1875$ K [8] as follows

$$k_i = \begin{cases} 1.3 + 1.6 \cdot \left(\frac{T_i}{1400}\right)^{1.7} \frac{W}{Km}, & 300K \leq T_i < 1400K \\ 2.9 - \frac{T_i - 1400}{475} \frac{W}{Km}, & 1400K \leq T_i < 1875K \\ 1.9 \frac{W}{Km}, & T_i \geq 1875K. \end{cases} \quad (2)$$

The temperature dependence is plotted in Fig. 1(b) and the experimentally reported values are summarized in Table I. The thermal conductivity k_i rises up to the annealing temperature. It then drops down to the melting point, according to the recent experimental measurements performed by using infrared thermography [8, 23]. This discontinuity significantly influences the temperature evolution in the multi-pulse accumulation regimes since the cooling time of the lattice is related to the diffusivity $D = k_i/\rho C_i$ as follows $\tau_{cool} = w_0^2/D$.

The corresponding temperature dependency of viscosity is described by the Vogel-Fulcher-Tammann (VTF) model, fitting the viscosity data for the intermediate temperatures over many orders of magnitude with high accuracy [26]

$$\log[\eta(T_i)] = A + B/(T_i - T_V), \quad (3)$$

where $A = -7.925$ and $B = 31555.9$ K are constants, and $T_V = -142$ K is Vogel's temperature. For fused silica, the parameters are taken from Ref. [27]. The resulting viscosity curve shown in Fig. 1(c) fits well the experimental measurements [28–30] and is consistent with the other models [26]. The structural relaxation time is defined as $\tau_M = \eta/G$, where the shear bulk modulus is taken equal to $G = 31$ GPa, in agreement with a number of the experimental measurements performed for a wide range of temperatures [11, 16, 25].

- [1] M. Lancry, F. Zimmerman, R. Desmarchelier, J. Tian, F. Brisset, S. Nolte, and B. Poumellec, *Applied Physics B* **122**, 1 (2016).
- [2] Y. P. Meshcheryakov, M. V. Shugaev, T. Mattle, T. Lippert, and N. M. Bulgakova, *Applied Physics A* **113**, 521 (2013).
- [3] D. Puerto, J. Siegel, W. Gawelda, M. Galvan-Sosa, L. Ehrentraut, J. Bonse, and J. Solis, *JOSA B* **27**, 1065 (2010).
- [4] S. Najafi, A. S. Arabanian, and R. Massudi, *Journal of Physics D: Applied Physics* **49**, 255101 (2016).
- [5] N. M. Bulgakova, R. Stoian, and A. Rosenfeld, *Quantum Electronics* **40**, 966 (2010).
- [6] E. A. Romanova and A. I. Konyukhov, *Optics and Spectroscopy* **104**, 784 (2008).
- [7] A. Couairon, L. Sudrie, M. Franco, B. Prade, and A. Mysyrowicz, *Phys. Rev. B* **71**, 125435 (2005).
- [8] P. Combis, P. Cormont, L. Gallais, D. Hebert, L. Robin, and J.-L. Rullier, *Applied Physics Letters* **101**, 211908 (2012).
- [9] P. Martin, S. Guizard, P. Daguzan, G. Petite, P. D'Oliveira, P. Meynadier, and M. Perdrix, *Phys. Rev. B* **55**, 5799 (1997).
- [10] M. Sakakura, M. Terazima, Y. Shimotsuma, K. Miura, and K. Hirao, *Las. Chem.* **2010**, 1 (2010).
- [11] R. L. Parc, C. Levelut, J. Pelous, V. Martinez, and B. Champagnon, *Journal of Physics: Condensed Matter* **18**, 7507 (2006).
- [12] M. Lenzner, J. Krüger, S. Sartania, Z. Cheng, C. Spielmann, G. Mourou, W. Kautek, and F. Krausz, *Phys. Rev. Lett.* **80**, 4076 (1998).
- [13] L. Hallo, A. Bourgeade, V. T. Tikhonchuk, C. Mezel, and J. Breil, *Phys. Rev. B* **76**, 024101 (2007).
- [14] J.-x. Cai, X. Qu, H. Li, and G.-y. Jin (2015) pp. 96711C–96711C–6.
- [15] M. Schmidt, F. Vollertsen, M. Geiger, K. Cvecek, I. Alexeev, I. Miyamoto, and M. Schmidt, *Physics Procedia* **5**, 495 (2010).

- [16] M. Fukuhara and A. Sanpei, Japanese Journal of Applied Physics **33**, 2890 (1994).
- [17] Y. Okamoto, I. Miyamoto, K. Cvecek, A. Okada, K. Takahashi, and M. Schmidt, Journal of Laser Micro Nanoengineering **8**, 65 (2013).
- [18] S. Quan, J. Hong-Bing, L. Yi, Z. Yong-Heng, Y. Hong, and G. Qi-Huang, Chinese Physics Letters **23**, 189 (2006).
- [19] M. Li, S. Menon, J. P. Nibarger, and G. N. Gibson, Phys. Rev. Lett. **82**, 2394 (1999).
- [20] A. Horn, H. Khajehnouri, E.-W. Kreutz, and R. Poprawe (2003) pp. 393–400.
- [21] C. Mauclair, K. Mishchik, A. Mermillod-Blondin, A. Rosenfeld, I.-V. Hertel, E. Audouard, and R. Stoian, Physics Procedia **12**, 76 (2011).
- [22] P. K. Velpula, M. K. Bhuyan, F. Courvoisier, H. Zhang, J. P. Colombier, and R. Stoian, Laser & Photonics Reviews **10**, 230 (2016).
- [23] T. Doualle, L. Gallais, P. Cormont, D. Hébert, P. Combis, and J.-L. Rullier, Journal of Applied Physics **119**, 113106 (2016).
- [24] R. Kraus, S. Stewart, D. Swift, C. Bolme, R. Smith, S. Hamel, B. Hammel, D. Spaulding, D. Hicks, J. Eggert, *et al.*, Journal of Geophysical Research: Planets **117**, 1 (2012).
- [25] J. Zhao, J. Sullivan, J. Zayac, and T. D. Bennett, Journal of Applied Physics **95**, 5475 (2004).
- [26] M. I. Ojovan, Physics and Chemistry of Glasses-European Journal of Glass Science and Technology Part B **53**, 143 (2012).
- [27] W. Martienssen and H. Warlimont, *Springer handbook of condensed matter and materials data* (Springer Science & Business Media, 2006).
- [28] G. Urbain, Y. Bottinga, and P. Richet, Geochimica et Cosmochimica Acta **46**, 1061 (1982).
- [29] R. H. Doremus, Journal of Applied Physics **92**, 7619 (2002).
- [30] J. A. Billo, J. Jones, W. Asghar, R. L. Carter, and S. M. Iqbal, Applied Physics Letters **100**, 233107 (2012).